Supporting Information

Enhanced visible light photocatalytic activity in BiOCl/SnO₂: heterojunction of two wide band-gap semiconductors

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Samples	Bi 4 <i>f</i> (eV)		Sn 3d (eV)		Cl 2 <i>p</i> (eV)		$O_{1}(aV)$
	$4f_{5/2}$	$4f_{7/2}$	$3d_{3/2}$	$3d_{5/2}$	$2p_{1/2}$	$2p_{3/2}$	O is (ev)
BiOCl	43.8%	56.2%	-	-	41.5%	58.5%	11.3% 25.0% 63.7%
SnO ₂	-	-	41.9%	58.1%	-	-	16.1% 28.0% 55.9%
0.5BiOCl/SnO ₂	42.5%	57.5%	42.5%	57.5%	42.3%	57.7%	32.8% 38.2% 29.0%

 Table S1 The results of each deconvoluted component of BiOCl, SnO2 and 0.5BiOCl/SnO2 composite



Fig.S1 TEM and HRTEM images of 0.5BiOCl/SnO₂



Fig.S2 HRTEM images of $0.5BiOCl/SnO_2$



Fig. S3. EDS spectrum of 0.5BiOCl/SnO₂ composite.



Fig. S4. XPS spectra of pure BiOCl: survey scan (a), Bi 4f (b), O1s (c) and Cl 2p (d).



Fig. S5. XPS spectra of pure SnO_2 : survey scan (a), Sn3d (b) and O1s (c).



Fig. S6. The adsorption behavior of BiOCl for ionic methyl orange (MO) and cationic methyl blue (MB).



Fig. S7. The photodegradation of RhB without any catalyst under visible light irradiation.



Fig. S8 The XRD patterns of $0.5BiOCl/SnO_2$ before and after degradation for 8 h



Fig.S9 Mott-Schottcky plots of 0.5BiOCl/SnO₂

The p-type and n-type characteristics of the semiconductors can be deduced from Mott-Schottky plots and equations as follows:¹

$$\frac{1}{C^2} = \frac{2}{e\varepsilon\varepsilon_0 N_{\rm A}} \left(E - E_{\rm fb} - \frac{kT}{e} \right) \text{ for n-type semiconctor}$$
(1)

$$\frac{1}{C^2} = \frac{2}{e\varepsilon\varepsilon_0 N_{\rm D}} \left(-E + E_{\rm fb} - \frac{kT}{e} \right) \text{ for p-type semiconductor}$$
(2)

Where ε_0 is the permittivity of vacuum (8.854×10⁻¹² F/m), ε is the dielectric constant of SnO₂ (ε =14) and BiOC1 (ε =5.59), and e is the electronic charge (1.603×10⁻¹⁹ C). N_D and N_A are the donor and acceptor densities, respectively, which are calculated from the slope of the fitting curves. *T* is the operation temperature (298 K), and *k* is Boltzmann's constant (1.38×10⁻²³ J/K). *E* is the electrode potential, E_{fb} is the flat-band potential, and *C* is the depletion-layer capacitance.



Fig. S10. The SPC spectra of pure BiOCl, SnO₂ and 0.5BiOCl/SnO₂ composite.

The surface photovoltage (SPV) technique is a rapid and effective method to study the photovoltaic properties of semiconductor photocatalysts. It always is used to investigate the transfer behavior of photo-induced charge carriers with high sensitivity to defect states at surface, bulk or any buried interface in the synthesized products.² Whenever the photo-induced charge carriers are separated, a photovoltage signal arises. Thus, the fundamental properties of the light absorption and the transport of excess carriers in the semiconductors decides the production of a SPV signal.^{3,4} That means the type of semiconductors (p-type or n-type), band-gap energy and gap states could be deduced from the SPV signals.⁵ A positive SPV signal indicates the photo-induced holes immigrate to the irradiation side of the product, and a negative SPV signal suggests that the photo-induced electrons move to the irradiation side. Furthermore, the threshold of the SPV response of semiconductors is generally consistent with the optical absorption.⁶

The SPV and SPC response intensities mostly depend on the charge separation efficiency. A higher separation efficiency of photo-induced charges would display a stronger SPV response intensity.⁷ The efficient separation of photo-induced electronhole pairs could prolong the lifetime of the charge carriers and improve the efficiency of the interfacial charge transfer to adsorbed substrates and then contributes to the higher photocatalytic activity of photocatalysts.⁸

When checking the SPV signals together with the corresponding phase spectrum, the detailed transfer direction and separation-recombination process of the photoinduced charge carriers could be deduced. Taking Cu₂O and ZnO films as an example,⁶ the phase value of Cu₂O film is about -140° and keep this value during the whole SPV response region, which indicates that negative charge accumulates at the surface of Cu₂O film. However, the phase value of ZnO film is about 20°, which suggests that the positive charge accumulates at the surface of ZnO film.

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